

<b>Notice of References Cited</b>		Application/Control No. 10/033,394	Applicant(s)/Patent Under Reexamination LEE ET AL.	
		Examiner Khiem D Nguyen	Art Unit 2823	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-5,340,770	08-1994	Allman et al.	438/548
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

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	N					
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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
*	U	IEEE 2000, phosphorus Ion Shower Implantation for Special Power IC Application's, F. Kroner, R. Schork, L. Frey, A. Burenko H. Ryssel , 4 pages
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.